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Appl. No. 09/681,817 Amdt. Dated March 4 2005 Reply to Office action of December 9, 2004

Claims Listing

1. (Amended Herein) A method for manufacturing a data storage media, comprising:

disposing an identifier layer onto a surface of a stamper, said stamper having primary surface features on a first side of said stamper opposite said identifier [layer] layer, said identifier layer comprising a managed heat transfer layer;

forming secondary features on an exposed surface of said identifier layer; installing said stamper into a mold;

injecting a molten plastic material into the mold, wherein said molten plastic physically contacts said first side; and

cooling said plastic to form said data storage media, such that a positive image of said primary surface features and of said secondary features are formed into at least a portion of a surface of said plastic.

- 2. (Original) The method of Claim 1, further comprising forming said secondary features with a laser beam.
- 3. (Original) The method of Claim 2, wherein said laser beam has wavelength of about 248 nm to about 308 nm.
- 4. (Original) The method of Claim 1, further comprising forming said secondary features by a plasma etching.
- 5. (Original) The method of Claim 1, further comprising forming said secondary features by photolithography.
- 6. (Amended Herein) The method of Claim 1, wherein said [identifier layer is a] managed heat transfer layer [comprising] comprises a material selected from the group consisting of polyimides, polyamideimides, polyamides, polysulfone, polyethersulfone, polytetrafluoroethylene, polyetherketone, and blends, copolymers, mixtures, reaction products, and composites comprising at least one of the foregoing materials.

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- 7. (Original) The method of Claim 6, wherein said material comprises polyimides.
- 8. (Original) The method of Claim 1, wherein said secondary features have valleys having a size equal to or greater than about 25 μm in valley width.
- 9. (Original) The method of Claim 8, wherein said valley width is greater than or equal to about 30 µm.
- 10. (Original) The method of Claim 9, wherein said valley width is greater than or equal to about 50 μm.
- 11. (Original) The method of Claim 1, wherein said secondary valley features have peaks having a peak width of greater than or equal to about 1 μ m.
- 12. (Original) The method of Claim 11, wherein said peak width is greater than or equal to about 5 um.
 - 13. (Original) The method of Claim 12, wherein said peak width is greater than or equal to about 10 µm.
 - 14. (Original) The method of Claim 1, further comprising spin coating said identifier layer onto said stamper.
 - 15. (Original) The method of Claim 1, wherein disposing said identifier layer onto said surface further comprises a method selected from the group consisting of bonding, laminating, vapor deposition, spraying, sputtering, and combinations comprising at least one of the foregoing methods.
 - 16. (Original) The method of Claim 1, wherein disposing said identifier layer on said surface further comprises forming said identifier layer and laminating said identifier layer to said stamper.

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- 17. (Original) The method of Claim 1, wherein said secondary features have a depth of about 0.05 μm to about 5.0 μm .
- 18. (Original) The method of Claim 1, wherein said secondary features have a depth of greater than or equal to about $5.0 \, \mu m$.
- 19. 24. (Previously Withdrawn)
- 25. (Original) A data storage media produced in accordance with the method of Claim 1.